

Attorney Docket No.: 0180154

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Please enter LP (3/23/06)

In re Application of: Jeon, et al.

Serial No.: 10/761,009

Filed: 01/20/2004

For: **Method for Forming a Thin, High Quality Buffer Layer in a Field Effect Transistor and Related Structure**

Art Unit: 2814

Examiner: Pham, Long

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AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir/Madam:

This is in response to the Final Office Action dated July 26, 2005 in the above-referenced patent application. Please enter and consider the following amendments and remarks.